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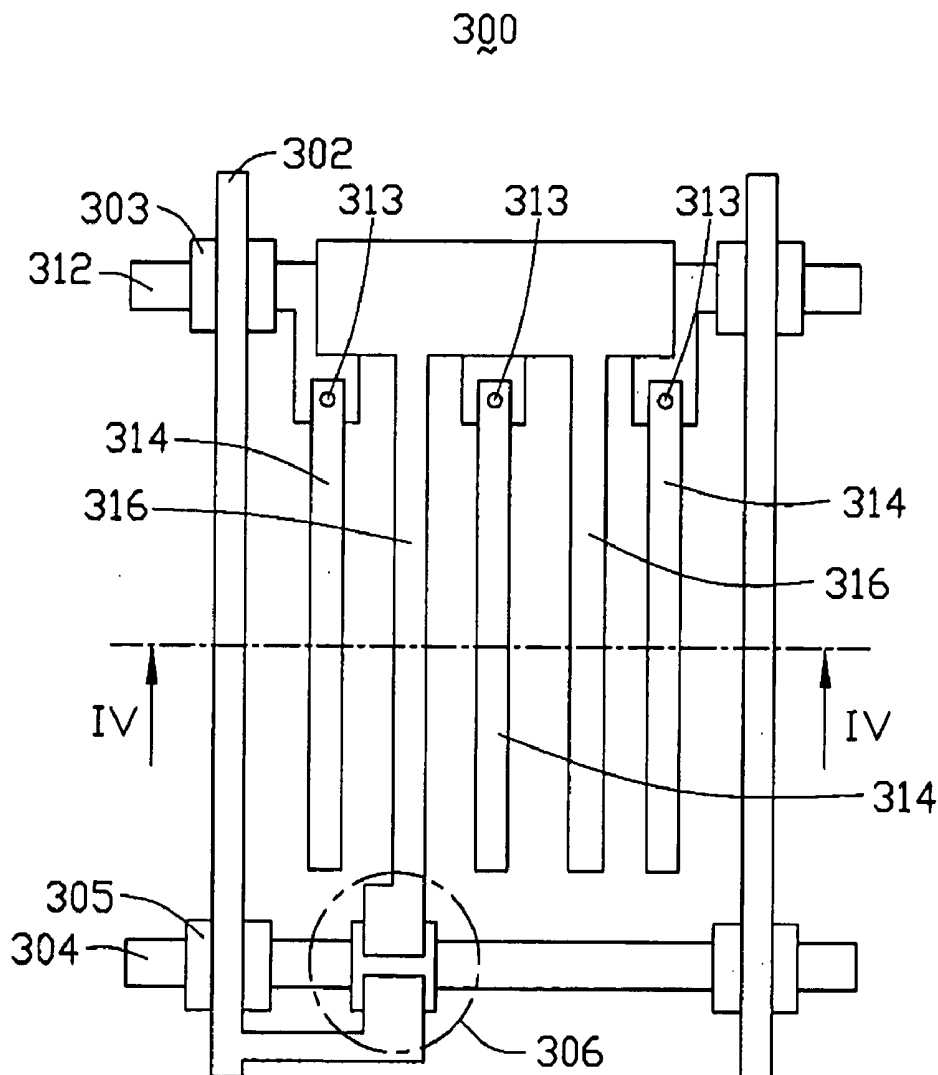
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(57) **ABSTRACT**

The present invention provides an in-plane switching liquid crystal display (IPS-LCD) device that includes a substrate, a protrusive layer having many protrusions on the substrate and a transparent electrode on each of the protrusions. One may dispose a color filter on the protrusions and fill in liquid crystal material between the color filter and the substrate. In contrast to conventional IPS-LCD devices, the IPS-LCD device of the present invention does not require the use of spacers. The present invention may thus largely enhance the light penetration rate and simplify the manufacturing process.

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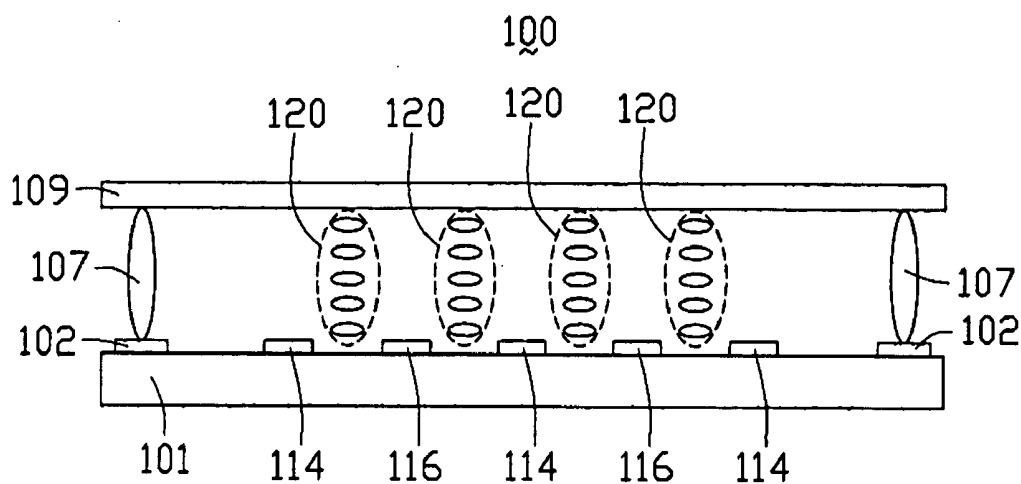


FIG. 2A  
(PRIOR ART)

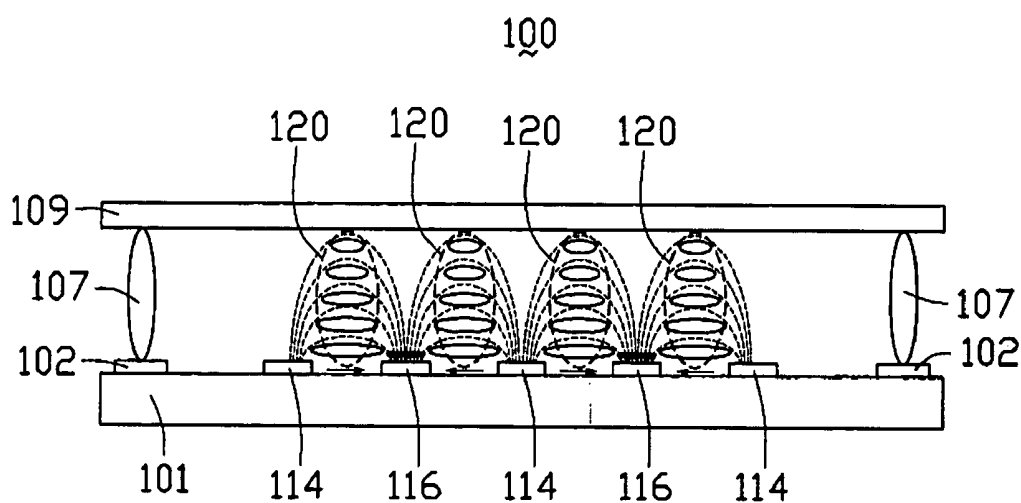
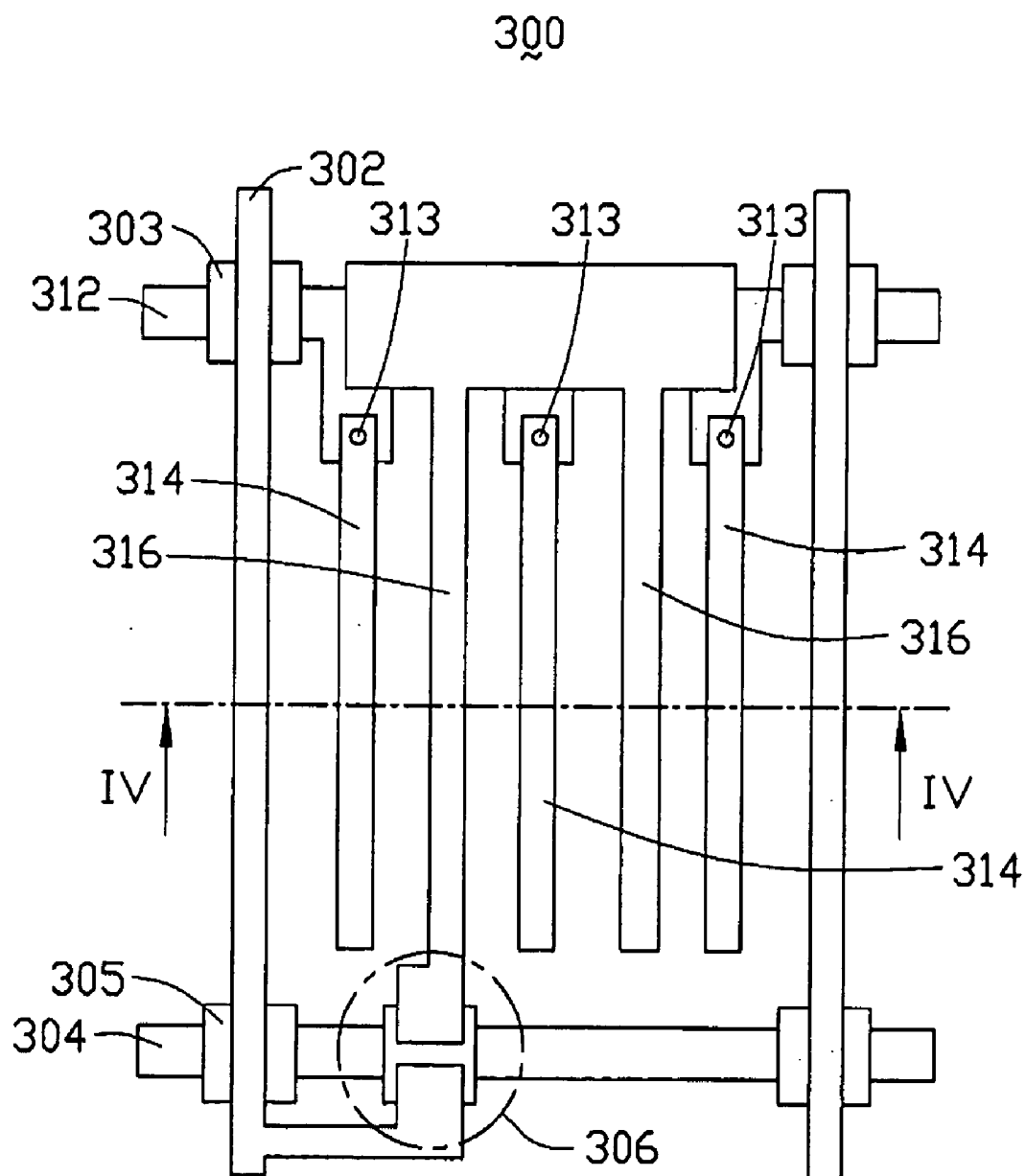


FIG. 2B  
(PRIOR ART)



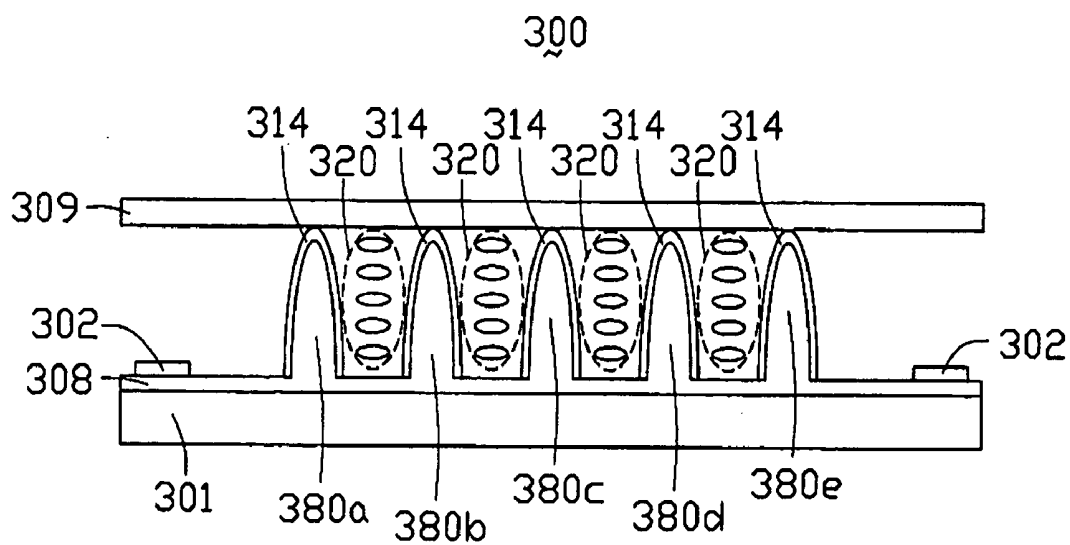


FIG. 4A

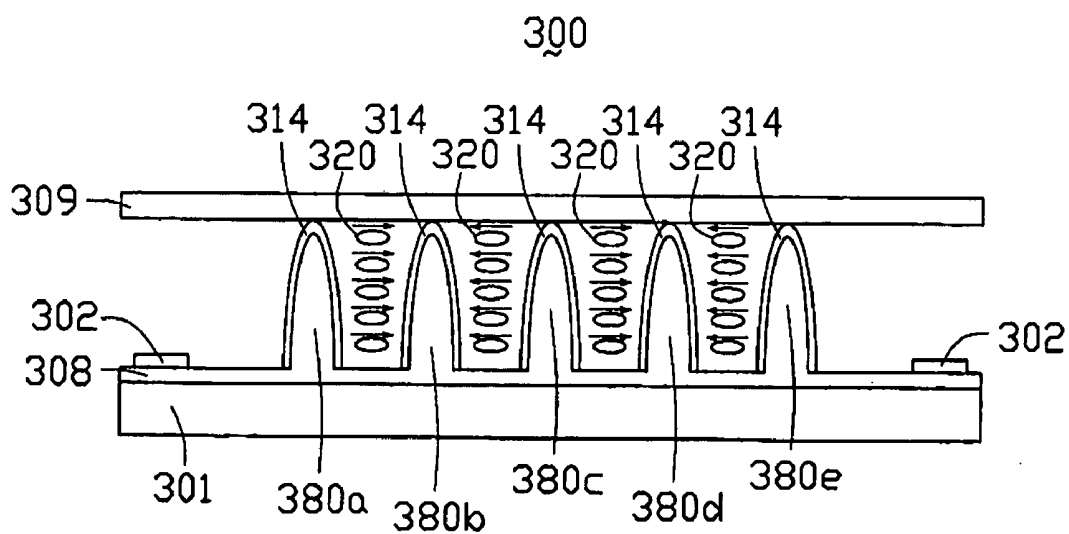


FIG. 4B

# IN-PLANE SWITCHING LIQUID CRYSTAL DISPLAY DEVICE AND METHOD FOR MANUFACTURING THE SAME

## BACKGROUND OF THE INVENTION

### [0001] 1. Field of the Invention

[0002] The present invention relates generally to a liquid crystal display (LCD) device and a method for manufacturing the same, and more particularly to an in-plane switching liquid crystal display (IPS-LCD) device and a method for manufacturing the same.

### [0003] 2. Prior Art

[0004] The invention of liquid crystal display (LCD) devices has revolutionized the way information is displayed. Its overwhelming application in almost all aspects of electronic products guaranteed its success in the market. However, for many years, LCD devices have suffered from its narrow viewing angles. This drawback is solved by many techniques. Among them, the most popular one is the so-called in-plane switching (IPS) technique, which is disclosed in U.S. Pat. No. 5,600,464, for example.

[0005] As shown in FIG. 1, a conventional IPS-LCD device 100 is illustrated. The IPS-LCD device 100 comprises a source line 102, a gate line 104, a common line 112, at least a counter electrode 114, at least a pixel electrode 116 and a thin film transistor (TFT) 106. The IPS-LCD device 100 further comprises an insulating layer 103 electrically separating the common line 112 and the source line 102, an insulating layer 105 electrically separating the gate line 104 and the source line 102, and at least a via 113 electrically connecting the counter electrode 114 with the common line 112.

[0006] Referring to FIG. 2A and FIG. 2B, wherein the cross-sectional views of line II-II of FIG. 1 are illustrated. As shown in FIG. 2A and FIG. 2B, the IPS-LCD device 100 comprises a substrate 101, a source line 102, at least a counter electrode 114, at least a pixel electrode 116, a spacer 107, a color filter 109 and liquid crystal material 120. The source line 102, the counter electrode 114 and the pixel electrode 114 are disposed on the substrate 101. The presence of the spacer 107 provides room between the color filter 109 and the substrate 101 so as to fill in the liquid crystal material 120. The IPS-LCD device 100 shown in FIG. 2A does not supply electric field to the liquid crystal material 120. Referring to FIG. 2B, electric field is now supplied to the liquid crystal material 120. The liquid crystal material 120 is thus rotated and aligned in response to the electric field supplied. The curved lines each having an arrow at one end, as shown in FIG. 2B, represent the electric field lines.

[0007] It is clearly seen from FIG. 2B that the electric field supplied to the liquid crystal material 120 near the substrate 101 is stronger than that supplied to the liquid crystal material 120 near the color filter 109. Therefore, the rotation angle of the liquid crystal material 120 adjacent the color filter 109 is less than that of the liquid crystal material 120 adjacent the substrate 101. These inhomogeneous rotation angles of the liquid crystal material 120, resulted from the inhomogeneous electric field distribution, may reduce the light penetration rate, hence lowering the display quality.

## SUMMARY OF THE INVENTION

[0008] In accordance with the above and other reasons, one objective of the present invention is to provide an

in-plane switching liquid crystal display (IPS-LCD) device and a manufacturing method thereof so as to supply a homogeneous electric field distribution.

[0009] Another objection of the present invention is to provide an IPS-LCD device and a manufacturing method thereof that do not require the use of spacers.

[0010] In order to achieve the above objectives, the present invention of an IPS-LCD device comprises a substrate, a protrusive layer having a plurality of protrusions and a transparent electrode on each of the protrusions of the protrusive layer. The transparent electrode on each of the protrusions is either a pixel electrode or a counter electrode. By covering a color filter on the protrusions, liquid crystal material may be filled in between the color filter and the substrate. Once the IPS-LCD device is switched on, a homogeneous electric field distribution is generated between the pixel electrode and the counter electrode. The liquid crystal material thus rotates to approximately the same angle due to the homogeneous electric field distribution. Therefore, the IPS-LCD device of the present invention has a higher light penetration rate. Furthermore, the IPS-LCD device of the present invention employs a plurality of protrusions to replace the conventional spacers. The manufacturing process is thus integrated to the fabrication of the protrusion layers, and therefore is reduced.

## BRIEF DESCRIPTION OF THE DRAWINGS

[0011] The present invention is better understood by referring to the detailed description of the preferred embodiment taken in conjunction with the drawings, wherein:

[0012] FIG. 1 illustrates a top view of a conventional IPS-LCD device;

[0013] FIG. 2A and 2B illustrate cross-sectional views taken along line II-II of FIG. 1;

[0014] FIG. 3 illustrates a top view of an IPS-LCD device according to the present invention; and

[0015] FIG. 4A and 4B illustrate cross-sectional views taken along line IV-IV of FIG. 3.

## DETAILED DESCRIPTION OF THE INVENTION

[0016] Hereinafter, the present invention is described in detail by incorporating with the accompanied drawings. For the convenience of explanation, it is appreciated that these drawings are not drawn to scale, but are schematic only.

[0017] Referring to FIG. 3, an IPS-LCD device 300 of the present invention is illustrated. The IPS-LCD device 300 comprises a source line 302, a gate line 304, a common line 312, at least a counter electrode 314, at least a pixel electrode 316 and a thin film transistor (TFT) 306. The source line 302 crosses the gate line 304 and the common line 312, thus defining a unit pixel as shown in the drawing. The IPS-LCD device 300 further comprises an insulating layer 303 electrically separating the common line 312 and the source line 302, an insulating layer 305 electrically separating the gate line 304 and the source line 302, and at least a via 313 electrically connecting the counter electrode 314 with the common line 312. The counter electrode 314 and the pixel electrode 316 are parallel to each other. In addition, the neighboring electrode of each pixel electrode is

a counter electrode, and vice versa. Furthermore, the TFT 306 of the IPS-LCD device 300 acts as a switch for turning on-and-off of the IPS-LCD device 300.

[0018] In order to further describe the particular features of the present invention, attention is now directed to FIG. 4A and FIG. 4B, wherein cross-sectional views taken along line IV-IV of FIG. 3 are illustrated. As shown in FIG. 4A and FIG. 4B, the IPS-LCD device 300 comprises a substrate 301, a protrusive layer 308 having a plurality of protrusions 308a, 308b, 308c, 308d and 308e, at least a counter electrode 314, at least a pixel electrode 316, a color filter 309 and liquid crystal material 320. In FIG. 4A, no electric field is supplied to the liquid crystal material 320. The substrate 301 is made of transparent solid materials such as glass and plastic material. The protrusive layer 308 is formed on the substrate 301, which is made of organic materials such as a transparent negative photoresist material. The protrusions 308a, 308b, 308c, 308d and 308e of the protrusive layer 308 are thus formed by means of photolithography techniques. In this particular embodiment, the source line 302 is deposited on protrusive layer 308 not on any of the protrusions 308a, 308b, 308c, 308d and 308e, while the counter electrode 314 is deposited on the protrusions 308a, 308c and 308e, and the pixel electrode 316 is deposited on the protrusions 308b and 308d. The deposition of the source line 302, the counter electrode 314 and the pixel electrode 316 are accomplished by sputtering a transparent conductive material, such as indium-tin-oxide (ITO). The color filter 309 is disposed on and supported by the protrusions 308a, 308b, 308c, 308d and 308e of the protrusive layer 308. In contrast to the spacer 107 of the conventional IPS-LCD device 100 as shown in FIG. 2A and FIG. 2b, the protrusions 308a, 308b, 308c, 308d and 308e of the present invention provides room between the color filter 309 and the substrate 301 so as to fill in the liquid crystal material 320.

[0019] FIG. 4B illustrates a cross-sectional view taken along line IV-IV of FIG. 3, wherein electric field is supplied to the liquid crystal material 320. As shown in FIG. 4B, the electric field supplied to the liquid crystal material 320 adjacent the substrate 301 is approximately equal to that supplied to the liquid crystal material 320 adjacent the color filter 309. Consequently, the present invention provides a homogeneous electric field distribution on the liquid crystal material 320, which is advantageous in that the light penetration rate is increased. In addition, the employment of the protrusions 308a, 308b, 308c, 308d and 308e does not require the employment of the spacer 107, as shown in FIG. 2A and FIG. 2B.

[0020] In summary, the method for manufacturing an in-plane switching liquid crystal display device of the present invention comprises the steps of: providing a sub-

strate; forming an organic material layer on the substrate; etching the organic material layer by means of a photolithography technique so as to obtain a plurality of protrusions; and depositing a transparent electrode on each of the protrusions. The method further comprises the step of: covering a color filter on the protrusions; and filling in liquid crystal material between the color filter and the substrate.

[0021] It is appreciated that the above discussion discloses only a preferred embodiment of the present invention. Any person having ordinary skill in the art may easily find various other embodiments equivalent to the present invention. Therefore, the scope of the present invention is covered by the appended claims as set forth in the following.

What is claimed is:

1. An in-plane switching liquid crystal display device, comprising:
  - a substrate;
  - a protrusive layer on said substrate, which includes a plurality of protrusions; and
  - a transparent electrode deposited on each of the protrusions.
2. The liquid crystal display device of claim 1, wherein said transparent electrode is either a pixel electrode or a counter electrode.
3. The liquid crystal display device of claim 1, wherein said protrusive layer is made of an organic material such as a transparent negative photoresist material.
4. The liquid crystal display device of claim 1, further comprising: a color filter covering said protrusions
5. The liquid crystal display device of claim 4, wherein liquid crystal material is filled in between said substrate and said color filter.
6. A method for manufacturing an in-plane switching liquid crystal display device, comprising the steps of:
  - (a) providing a substrate;
  - (b) forming an protrusive layer having a plurality of protrusions on said substrate; and
  - (c) depositing a transparent electrode on each protrusion of said protrusive layer.
7. The method of claim 6, wherein the step (b) further comprising:
  - (d) forming an organic material layer on said substrate;
  - (e) etching the organic material layer by means of a photolithography technique to obtain a plurality of protrusions.

\* \* \* \* \*

|                |                                                     |         |            |
|----------------|-----------------------------------------------------|---------|------------|
| 专利名称(译)        | 面内切换液晶显示装置及其制造方法                                    |         |            |
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| 申请号            | US10/818905                                         | 申请日     | 2004-04-05 |
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#### 摘要(译)

本发明提供一种面内切换液晶显示器 ( IPS-LCD ) 装置，其包括基板，在基板上具有许多突起的突出层和在每个突起上的透明电极。可以在突起上设置滤色器并在滤色器和基板之间填充液晶材料。与传统的IPS-LCD设备相比，本发明的IPS-LCD设备不需要使用间隔物。因此，本发明可以在很大程度上提高光穿透率并简化制造工艺。

